

Kemet Polishing Pads

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Flat polished surfaces can only be produced on many softer materials with the use of polishing pads. These are available to suit most flat lapping machines. Kemet offer the widest range of self-adhesive polishing pads, of which there are three general types:

Synthetic Silk Pads

A range of synthetic silk pads with a durable woven structure that produces flat mirror surfaces on stainless steels, stellite and many other metals.

ASFL-AW - for optimum flat mirror polishing of many metals. This pad is available with adhesive resistance to oil or water, to suit the polishing abrasive being used.

ASF-AW - this silk pad has a self-adhesive cloth backing which is resistant to water. It produces mirror surfaces, but is more suitable for cosmetic finishes on products, such as jewellery, where flatness is not crucial.

Chemo Textile Pads

Non woven pads manufactured specially for polishing processes.

PSU - available in soft, medium and hard. Used with Diamond and Non Diamond abrasives. A good general purpose pad with a relatively long life.

CHEM - for use with **COL-K** polish for chemical mechanical polishing processes, which are required for many specialised materials, such as titanium and cobalt chrome.

Nap Cloths

Particularly suitable for the softer materials and metals.

NMH - unidirectional fibres bonded to a cotton twill backing, durable and wear resistant.

NLH - a longer and stiffer nap cloth used for some optical polishing operations.



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	CODE	CODE
Type	380mm Dia	610mm Dia
PSU - S	341016	341043
PSU - M	341011	341012
PSU - H	341004	341006
ASFL - AW	341112	341113
ASF - AW	341109	341145
CHEM	341927	341930
NMH	341221	341252
NLH	341248	341253

A wide range of other special pads are available on request.